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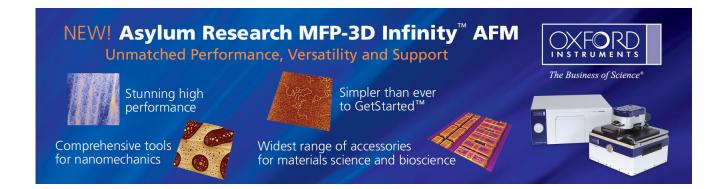
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Fabrication and low temperature thermoelectric properties of Na_xCoO_2 (x=0.68 and 0.75) epitaxial films by the reactive solid-phase epitaxy

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The authors have fabricated Na_xCoO_2 thin films via lateral diffusion of sodium into Co_3O_4 (111) epitaxial films (reactive solid-phase epitaxy [Ohta *et al.*, Cryst. Growth Des. **5**, 25 (2005)]). The environment of thermal diffusion is key to the control of the sodium content in thin films. From the results of x-ray diffraction and in-plane ρ_{ab} , the epitaxial growth and the sodium contents of these films were identified. The thermoelectric measurements show a large thermoelectric power similar to that observed in single crystals. The quasiparticle scattering rate is found to approach zero at low temperatures, consistent with the small residual resistivity, indicating high quality of the Na_xCoO_2 thin films. © 2007 American Institute of Physics. [DOI: 10.1063/1.2437131]

The research on sodium cobaltate Na_xCoO₂ (NCO) has led to observations of many unusual physical properties exhibited in related compounds, such as the thermoelectric power, charge ordered insulator at x=0.5, and antiferromagnetic metal at x=0.75. Furthermore, the discovery of superconductivity in Na_xCoO₂·yH₂O was indeed a surprise.³ Many theoretical and experimental works have focused on the fascinating and yet puzzling ground states of NCO due to its two-dimensional triangular lattice and the mixed valence character. For the purpose of research and applications, scientists have been trying to fabricate NCO in its thin film form with modulated sodium concentrations x. Owing to the high vapor pressure of Na, however, it is difficult to directly grow high-quality epitaxial NCO thin films by pulsed-laser deposition, not to mention controlling x. Very recently, reactive solid-phase growth via lateral diffusion of sodium was reported as a viable method of growing epitaxial NCO thin films.4 However, precise control of sodium content and related characterizations remains to be resolved. In this letter, we report a capped-sandwich lateral diffusion scheme capable of fabricating high-quality epitaxial NCO films with well-controlled sodium contents.

In order to overcome the high vapor pressure of sodium and its associated detrimental consequences in the firsthand growth of NCO thin films, we divided the procedures of growing epitaxial NCO (0001) films into two parts. First, a layer of \sim 125 nm thick Co₃O₄ (111) thin film was deposited on sapphire (0001) substrates by pulsed-laser deposition (KrF excimer laser, λ =248 nm) with $T_{\rm substrate}$ =680 °C and $P_{\rm oxygen}$ =0.2 Torr. Subsequently, thermal-diffused sodium

was deployed to the obtained Co₃O₄ (111) to intercalate so-

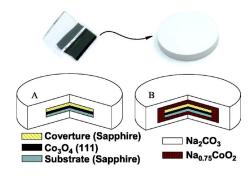


FIG. 1. (Color online) Schematics of the encapsulation schemes for preparing NCO thin films with x=0.68 (specimen A) and 0.75 (specimen B). The diameter of the pellets is 20 mm, and the size of the substrates is about 5×5 mm².

dium into the CoO₂ layers. In our scheme, in order to keep the film surface clean and smooth during the sodium diffusion process, the Co₃O₄ (111) film was capped with a sapphire sheet as a sandwich arrangement. This fabrication process has been developed by Ohta et al.4 The process is named the reactive solid-phase epitaxy (R-SPE). For more details, see Ref. 5. In order to fabricate Na_{0.68}CoO₂ (NCO068) film, we used sodium carbonate powder to muffle the "sandwiched" Co₃O₄ (111) film and pressed the whole assembly into a pellet, depicted as specimen A in Fig. 1. The lateral diffusion process was carried out at 700 °C for 10 h and cooled in air with the rate <10 °C/h. For preparing the Na_{0.75}CoO₂ (NCO075) film, the sandwiched Co₃O₄ (111) film was first muffled by NCO075 powder obtained by rapid heat-up sintering⁶ and then encapsulated in Na₂CO₃, as depicted schematically in Fig. 1 (specimen B). The pellet was then kept at 750–800 °C with oxygen flow for 5 h. After the

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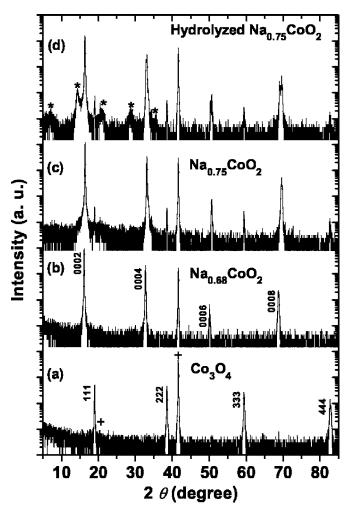


FIG. 2. XRD θ – 2θ scans of the as-grown samples of (a) Co₃O₄, (b) NCO068, and (c) NCO075 films. (d) was measured after exposing the NCO075 film in the ambient environment at T=25 °C and humidity of 42% for 1 h. The symbols + and * label the sapphire substrate and sodium hydroxide hydrate (NaOH·yH₂O) peaks, respectively. The * labeled peaks of NaOH·yH₂O can be indexed from the database, but y is still undetermined.

lateral diffusion of sodium, the Co_3O_4 (111) films evidently converted into NCO (0001) films with the thickness expanding to \sim 250 nm.

Alternatively, Venimadhav et al.⁷ have NaCOOCCH₃ powder to cover Co₃O₄ (111) films in the annealing process to obtain NCO075 films. However, there were some unsettled issues concerning the uniformity and surface quality of the films obtained by that scheme. We also had tried other process schemes to obtain specimens with x > 0.7. For instance, the pellet of specimen A was annealed at 800 °C for a few hours then quenched immediately in liquid nitrogen from 800 °C to keep as much sodium in the film as possible. However, the obtained films, though evidently displayed characteristics of NCO075, usually exhibited large residual resistivity indicating that there are more defects in the samples that presumably resulted from quenching in liquid nitrogen. In contrast, with the specimen B scheme depicted in Fig. 1, we have been able to obtain NCO075 films reproducibly with very good uniformity and surface conditions. It is suggestive from the apparent concentration of the quenched samples that, even for the scheme of specimen A, the equilibrium sodium concentration at high temperature may have reached $x \ge 0.75$ with the encapsula-

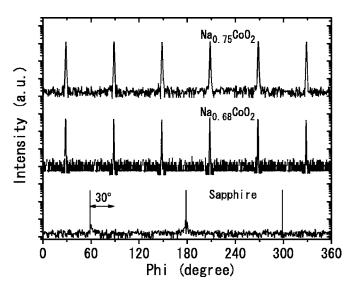


FIG. 3. Φ scans of the (1 $\overline{104}$) peak of the NCO films and the sapphire substrate indicate the relative rotation as well as the excellent epitaxial relations between films and substrate.

tion of Na_2CO_3 powders. The slow cooling practiced in scheme A, albeit being necessary for small residual resistivity, inevitably loses some sodium and finally arrives at the stable concentration of x=0.68

The crystal structure and sodium concentration of NCO thin films were carefully examined by x-ray diffraction (XRD) measurements. The results of θ -2 θ and Φ scans are shown in Figs. 2 and 3, respectively. The lattice mismatch between the NCO films [a=2.8407(2) Å for specimen A and]a=2.843(1) Å for specimen B] and the sapphire substrate (a=4.760 Å) is reduced down to $\sim 3\%$ by a 30° in-plane rotation with respect to sapphire $(1 \ \overline{1} \ 00)$, as being illustrated in the Φ scan results of Fig. 3. The results of Figs. 2 and 3 show that Co₃O₄ (111) films were grown epitaxially on sapphire (0001) substrates, similar to the results obtained by Ohta et al. 4 and Venimadhav et al. 7 The NCO films obtained by both lateral diffusion schemes are also shown to be highly epitaxial to the substrate, albeit becoming (0001) oriented. Since in NCO cobaltates there exists an intimate correlation between the crystal structure parameters and Na content in the material, we inferred the Na content of the obtained NCO films by comparing the lattice constants with the structure phase diagram. From the c-axis lattice constants of specimens A [c=10.9328(8) Å] and B [c=10.877(3) Å], the inferred sodium concentrations for A and B are x=0.68 and 0.75, respectively. In addition, we noted that the NCO075 films instantly react with carbon dioxide and moisture in the ambient environment resulting in loss of sodium. This behavior is reflected in the XRD results shown in Figs. 2(c) and 2(d), in which there are still traces of the Co_3O_4 (111) phase. $\rho_{ab}(T)$ is another indication of sodium loss [Fig. 4(a)] where a bended ρ -T curve characterizing NCO075 turned into a linearlike curve for NCO068 accompanied by a larger residual resistivity after a short period of exposure in air.

The $\rho_{ab}(T)$ measurements were carried out down to 0.4 K by the four-probe method. The $\rho_{ab}(T)$ curves shown in Fig. 4 display an exactly identical temperature dependent behavior to that obtained from single crystals² with similar sodium contents of x=0.68 and 0.75, respectively, indicating the consistency of inferring the film composition by the

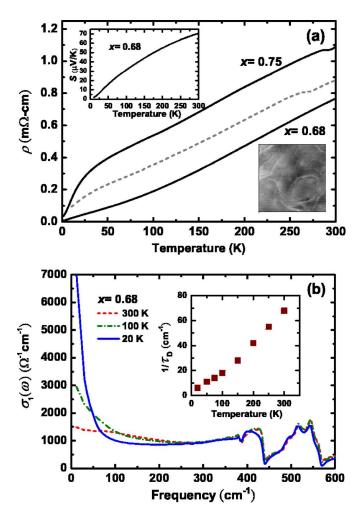


FIG. 4. (Color online) (a) In-plane resistivity ρ_{ab} vs T curves (solid lines) of NCO thin films with x=068 and 0.75. The gray dash line illustrates the ρ_{ab} -T of hydrolyzed NCO075 in Fig. 2(d). Upper inset: S(T) measurement for NCO068. Lower inset: atomic force microscopic image ($5 \times 5 \mu m^2$ and rms=1.67 nm) of NCO068 thin films was measured after thermal-diffusion process. (b) Temperature dependence of the far-infrared conductivity of the NCO068 thin film. The inset shows the temperature dependence of the Drude scattering rate $1/\tau_D$.

structural and transport property comparisons. Our films notably show an even smaller residual resistivity with the residual resistivity ratios RRR $\equiv \rho(300 \text{ K})/\rho(0.4 \text{ K}) = 145 \text{ and}$ 37, which are comparable or better than the RRR of the single crystals in Ref. 2, for x=0.68 and 0.75, respectively. In addition, the ρ_{ab} -T of hydrolyzed NCO075 is illustrated by the gray dash line, which shows the characteristic of lower sodium concentration (x < 0.75) and larger residual resistivity. The in-plane Seebeck coefficient S(T) represents yet another prominent property of this class of materials. We used a calibrated chip resistor glued to one end of the thin film as a pulsed-heat source. The temperature gradient was measured by using a differential thermocouple, and the corresponding Seebeck voltage was measured between the two signal leads connected by a pair of copper wires. The upper left inset of Fig. 4(a) shows that S(300 K) is nearly 80 μ V/K and is strongly temperature dependent for the NCO068, consistent with the results of single crystals in the previous literature.9 Unfortunately, due to the rapid deteriorating effects mentioned above, S(T) for NCO075 thin films is not available yet. In any case, the results presented above indicate that the preparation schemes in this letter can indeed produce films with very high quality.

Finally, we discuss briefly the implications of low residual resistivity at low temperatures. For this purpose, infrared spectroscopy has been proven to be the effective tool for the analysis of the transport properties of a broad range of conducting systems. ¹⁰ Figure 4(b) shows the temperature dependent behavior of the far-infrared conductivity spectra for the NCO068 film. At 300 K, the low-frequency conductivity for ω < 100 cm⁻¹ can be described by a Drude peak, which grows in intensity and sharpens as the temperature is lowered. By fitting the Drude conductivity and the measured infrared reflectance self-consistently, a nearly temperature independent Drude plasma frequency $\omega_{\rm pD} \sim 2400~{\rm cm}^{-1}$ is obtained, whereas the scattering rate $1/\tau_D$ monotonically decreases with decreasing temperature [see the inset of Fig. 4(b)]. Such behavior is typical of conventional metals.¹¹ Notably, the $1/\tau_D(20 \text{ K})$ is about 6 cm^{-1} compared with $1/\tau_D(300 \text{ K}) = 68\text{cm}^{-1}$, consistent with the small residual resistivity (or large RRR). Since the residual resistivity and $1/\tau_D(20 \text{ K})$ are proportional to the concentration of impurities or defects in the film, the transport and optical results indicate the high quality of the NCO068 thin film.

In summary, NCO thin films with x=0.68 and 0.75 were fabricated via R-SPE.⁴ The thin film quality is at least as decent as that of single crystals, judging from the results of XRD, $\rho_{ab}(T)$, and S(T) curves. The environmental control of different equilibrium Na vapor pressures are achieved reproducibly by the present encapsulation schemes, which presumably have been very effective in providing sodium needed for forming NCO and at the same time preventing moisture from getting in to the films.

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